

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of: Cecile BERNE et al.

Confirmation No.

Application No.:

Group Art Unit:

Filing Date:

Examiner:

For: TWO STAGE ANNEALING METHOD FOR
MANUFACTURING SEMICONDUCTOR
STRUCTURES

Attorney Docket No.: 4717-5499

**POWER OF ATTORNEY BY ASSIGNEE
AND EXCLUSION OF INVENTOR(S) UNDER 37 C.F.R. 3.71**

Commissioner for Patents
P.O. Box 1450
Alexandria, Virginia 22313-1450

Sir:

The undersigned assignee of the entire interest in the above-identified subject application hereby appoints Allan A. Fanucci (Reg. No. 30,256) and Daniel J. Hulseberg (Reg. No. 36,554) of WINSTON & STRAWN LLP (Customer No. 28765) to prosecute this application and to transact all business in the United States Patent and Trademark Office connected therewith.

Please direct all correspondence for this application to Customer No. 28765 to the attention of Allan A. Fanucci (telephone 212-294-3311, facsimile 212-294-4700).

An assignment of the entire interest in the above-identified subject application:

- ☒ is submitted herewith for recording and a copy is attached.
☐ was submitted for recordation on _____ and a copy is attached.
☐ was recorded on _____ at Reel _____, Frame _____.

The undersigned has reviewed this assignment and, to the best of his/her knowledge, title is in the assignee seeking to take action in this application and that he/she is empowered to act on its behalf.

ASSIGNEE: S.O.I. TEC SILICON ON INSULATOR TECHNOLOGIES S.A.

Signature:

Date of Signature:

Typed Name:

Position/Title:

Address:

[Signature]

Jan 13th 2004

C. HUYGHE

IP Manager

Parc Technologique des Fontaines

F-38190 Bernin, France

ASSIGNEE:

COMMISSARIAT À L'ÉNERGIE ATOMIQUE (CEA)

R. NAGEL

Chef de Service

Signature:



Date of Signature:

22/01/2004

Typed Name:

RICHARD NAGEL

Position/Title:

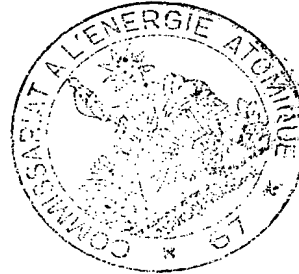
HEAD OF DSC/SCPIA

Address:

Etablissement Public de caractère scientifique et industriel

31-33 rue de la fédération, 75752 Paris, France

Direction Juridique et des Relations Commerciales
Service Central de la Propriété Industrielle et des Accords
CEA/SACLAY
Bât. 446
91191 GIF SUR YVETTE CEDEX



ASSIGNMENT

WHEREAS, each of,

Cecile BERNE, a citizen of France, residing at
3 bis rue Elisée Recluse, 38100 Grenoble, France;

Bruno GHYSELEN, a citizen of France, residing at
58 rue Georges Maeder, 38170 Seyssinet-Pariset, France;

Chrystelle LAGAHE, a citizen of France, residing at
Route de la cascade, 38134 St Joseph de Rivière, France; and.

Thibaut MAURICE, a citizen of France, residing at
2 rue Antonine Renavant, 38100 Grenoble , France.

ASSIGNOR, are each inventors of the invention entitled: **TWO STAGE ANNEALING METHOD FOR MANUFACTURING SEMICONDUCTOR STRUCTURES**, for which a United States non-provisional patent application is identified by Winston & Strawn Docket No. **4717-5499** and was filed on December 10, 2003 as Application No.

WHEREAS, **S.O.I. TEC SILICON ON INSULATOR TECHNOLOGIES S.A.**, a French corporate body having a place of business at Parc Technologique des Fontaines, F-38190 Bernin, France, and **COMMISSARIAT À L'ENERGIE ATOMIQUE (CEA)**, a French corporate body having a place of business at Etablissement Public de caractère scientifique et industriel, 31-33 rue de la fédération, 75752 Paris, France, ASSIGNEES, are desirous of jointly obtaining my entire right, title and interest in, to and under the said invention and the said application.

NOW, THEREFORE, in consideration of the sum of One Dollar (\$1.00) to each inventor in hand paid, and other good and valuable consideration, the receipt of which is hereby acknowledged, each ASSIGNOR has sold, assigned, transferred and set over, and by these presents does hereby sell, assign, transfer and set over, unto the said ASSIGNEE, its successors, legal representatives and assigns, his or her entire right, title and interest in, to and under the said invention, and the said United States application and all divisions, renewals and continuations thereof, and all Patents of the United States which may be granted thereon and all reissues and extensions thereof;

And each ASSIGNOR hereby authorizes and requests the Commissioner of Patents and Trademarks of the United States, and any Official of any country or countries foreign to the United States, whose duty it is to issue patents or other evidence or forms of industrial property protection on applications as aforesaid, to issue the same to the said ASSIGNEES, its successors, legal representatives and assigns, in accordance with the terms of this instrument;

And each ASSIGNOR hereby covenants and agrees that they have full right to convey the entire interest herein assigned, and that they have not executed, and will not execute, any agreement in conflict herewith;

And each ASSIGNOR further covenants and agrees that they will communicate to the said ASSIGNEES, and their successors, legal representatives and assigns, any facts known to them respecting said invention, and testify in any legal proceeding, sign all lawful papers, execute all divisional, continuing, reissue and foreign applications, make all rightful oaths, and generally do everything possible to aid the said ASSIGNEES and their successors, legal representatives and assigns, to obtain and enforce proper protection for said invention in all countries;

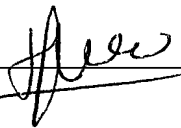
And each ASSIGNOR hereby authorizes the ASSIGNEES' patent attorney to complete this form by the addition of the application number, application filing date, and attorney docket number, if necessary.

In witness whereof, each inventor has affixed his or her signature.

Date Jan 19, 2004


Cecile BERNE

On Jan 19th, 2004, before me, C. HUYGHE,
Witness, appeared **Cecile BERNE**, to me known and known to me to be the person of that name, who signed the foregoing instrument, and acknowledged the same to be his/her free act and deed.

Witness 

Date Jan. 20th, 2003


Bruno GHYSELEN

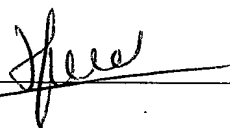
On Jan 20th, 2003, before me, C. HOYGENE,
Witness, appeared **Bruno GHYSELEN**, to me known and known to me to be the person of
that name, who signed the foregoing instrument, and acknowledged the same to be his/her
free act and deed.

Witness 

Date Jan 20th, 2004


Chrystelle LAGAHE

On Jan 20th, 2003, before me, C. HOYGENE,
Witness, appeared **Chrystelle LAGAHE**, to me known and known to me to be the person of
that name, who signed the foregoing instrument, and acknowledged the same to be his/her
free act and deed.

Witness 

Date 01/13, 2004


Thibaut MAURICE

On January 13th, 2004, before me, C. HOYGENE,
Witness, appeared **Thibaut MAURICE**, to me known and known to me to be the person of
that name, who signed the foregoing instrument, and acknowledged the same to be his/her
free act and deed.

Witness 